

Comparative optical study of Eu³⁺ ions doping in InGaN/GaN quantum dots and GaN layer grown by molecular beam epitaxy

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Abstract: We report on a comparative optical study of InGaN:Eu quantum dots (QDs) and GaN:Eu layer grown by molecular beam epitaxy (MBE). Analysis of the $^5D_0 \rightarrow ^7F_2$ transition as a function of the excitation wavelength shows that Eu³⁺ ions in InGaN:Eu QDs are located inside InGaN QDs and also in the GaN barrier layer. The existence of Eu³⁺ ions in the GaN barrier layer is explained by Eu segregation/diffusion during growth. For Eu³⁺ ions located inside InGaN QDs the photoluminescence (PL) shows only a slight decrease with temperature from 5 K to 300 K. In contrast, the PL from Eu³⁺ ions in the GaN barrier layer or in GaN thick layer shows a much more pronounced thermal quenching. ?? 2005 Elsevier B.V. All rights reserved.

Index Keywords: Gallium nitride; Molecular beam epitaxy; Photoluminescence; Semiconducting indium compounds; Semiconductor doping; Semiconductor quantum dots; Excitation wavelength; Thermal quenching; Europium

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